Probing dark excitons in atomically thin semiconductors via near-field coupling to surface plasmon polaritons

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Transition metal dichalcogenide (TMD) monolayers with a direct bandgap feature tightly bound excitons, strong spin–orbit coupling and spin–valley degrees of freedom1–4. Depending on the spin configuration of the electron–hole pairs, intra-valley excitons of TMD monolayers can be either optically bright or dark5–8. Dark excitons involve nominally spin-forbidden optical transitions with a zero in-plane transition dipole moment6, making their detection with conventional optical techniques challenging. Here, we introduce a method for probing the optical properties of two-dimensional materials via near-field coupling to surface plasmon polaritons (SPPs). This coupling selectively enhances optical transitions with dipole moments normal to the two-dimensional plane, enabling direct detection of dark excitons in TMD monolayers. When a WSe2 monolayer is placed on top of a single-crystal silver film9, its emission into near-field-coupled SPPs displays new spectral features whose energies and dipole orientations are consistent with dark neutral and charged excitons. The SPP-based near-field spectroscopy significantly improves experimental capabilities for probing and manipulating exciton dynamics of atomically thin materials, thus opening up new avenues for realizing active metasurfaces and robust optoelectronic systems, with potential applications in information processing and communication10.

When an optical dipole is in proximity to a metallic substrate, it can emit light into both far-field photons and surface plasmon polaritons (SPPs). Far-field emission can be measured directly via top-down optical microscopy, whereas SPP emission can be detected by converting SPPs into far-field light via engineered out-coupling structures (Fig. 1a). On a single-crystal silver film—our metal of choice due to its low loss10—SPPs are strongly polarized in the out-of-plane (z) direction in the visible frequency range (see Supplementary Section I). Consequently, the emission rate into SPPs is much greater for an out-of-plane dipole than for an in-plane dipole (Fig. 1b,c), with the enhancement factor exceeding 30 for the present device parameters (Fig 1d; for details of the analysis see Supplementary Sections II–III). At the same time, far-field emission of an in-plane dipole is strongly suppressed (Fig. 1b,d), because the in-plane electric field is close to zero near the silver surface. We note that when a point dipole is close to a metal12, non-radiative recombination due to ohmic loss can be the dominant decay mechanism. However, for delocalized excitons in quantum wells13 and two-dimensional materials, quenching of exciton luminescence by ohmic loss is significantly reduced, even when they are placed 10 nm above a silver surface (Supplementary Fig. 1 and Supplementary Section III). Combined together, the net effect of a nearby silver surface is significantly enhanced (suppressed) emission of an out-of-plane (in-plane) dipole into SPPs (the far field).

In the present experiment we used exfoliated monolayers of WSe2 or MoSe2 encapsulated between thin, insulating hexagonal boron nitride (hBN) flakes. The photoluminescence spectra of these heterostructures exhibit narrow excitonic features (linewidths of ~2–4 meV) at 4 K. A transition metal dichalcogenide (TMD) monolayer encapsulated by hBN is placed on atomically smooth single-crystal silver10. In our devices, silver plays dual roles: it supports SPPs that can be coupled to TMD excitons and it serves as a gate electrode that can change the electrostatic potential of a TMD monolayer (Fig. 1a). The spacing between the monolayer and the silver surface is determined by the bottom hBN thickness and can easily be controlled by varying this thickness. In our devices, the typical spacing was on the order of 10 nm.

Excitons were created using off-resonant 660 nm laser excitation, and the photoluminescence (PL) spectra were collected either from the same spot excited by the laser via far-field imaging (FF-PL), or from scattered SPPs at the out-coupling structures (SPP-PL, inset of Fig. 1e). At 4 K, the FF-PL spectrum of WSe2 displays several commonly observed spectral features, assigned previously to neutral exciton emission (X0), charged exciton emission (X+) and the lower-energy emission (L1) often attributed to defects14. Although X0 and X+ are known to have only in-plane transition dipole moments15. The SPP-PL spectrum, however, exhibits an additional large peak (XD) at 731 nm that is absent in the far-field spectrum, with a narrower linewidth (~2 meV) than the other spectral features. In contrast, neither the FF-PL nor SPP-PL spectra of monolayer MoSe2 exhibit the feature corresponding to XD in WSe2 SPP-PL (Supplementary Fig. 2). These observations suggest that the WSe2-specific XD feature is associated with an out-of-plane transition dipole moment that preferentially couples to SPPs.

To further explore the nature of excitonic species in monolayer TMDs, we compared the FF-PL and SPP-PL spectra for monolayer WSe2 and MoSe2 as we tuned the carrier density by means of a gate voltage. It is well known that the neutral exciton emission (X0) of TMD monolayers only exists inside the bandgap16. Once electrons or holes are added to the conduction band (CB) or valence band (VB) of the TMD monolayers via electrostatic doping by a gate

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The gate-dependent SPP-PL spectra of a WSe$_2$ monolayer in Fig. 2b show that emission from XD exists only within the same voltage range as the bright neutral exciton $X_0$. Because it is known to involve a purely out-of-plane transition dipole moment, the ratio of SPP-PL intensity determined by experiment is close to 7, in good agreement with the theoretical calculations. Figure 3b shows that the value of the normalized coupling ratio in WSe$_2$ is large not only for the neutral exciton peak $X_0$ at 731 nm, but also for the L1 peak at 740 nm. Specifically, in the bandgap region ($-2.5 \text{ V} < V_g < 0 \text{ V}$), voltage, the emission from $X_0$ vanishes, and the photoluminescence spectra are dominated by the charged exciton emission, $X_T$. In Fig. 2a–d and in Supplementary Figs 2 and 3, such trends are evidenced by the simultaneous disappearance of $X_0$ and the onset of in-plane conduction outside the bandgap region ($-2.5 \text{ V} < V_g < 0 \text{ V}$). The gate-dependent SPP-PL spectra of a WSe$_2$ monolayer in Fig. 2b show that emission from $X_0$ exists only within the same voltage range as the bright neutral exciton $X_0$.

Outside the bandgap region, additional optical transitions with an out-of-plane dipole orientation emerge. Figure 3a,b presents the FF-PL and SPP-PL spectra of WSe$_2$ at different gate voltages. We normalized both FF-PL and SPP-PL spectra using the intensity of a charged exciton peak $X_T$, because it is known to involve a purely in-plane transition dipole moment. The ratio of SPP-PL intensity to the FF-PL intensity after normalization provides a direct measure of the orientation of the transition dipole for each luminescent species: the unity ratio represents a purely in-plane dipole, and a value larger than one indicates that the transition dipole has some out-of-plane components. Based on our theoretical calculations presented in Fig. 1d and Supplementary Fig. 4, an optical transition with a purely out-of-plane transition dipole should have a normalized coupling ratio of 7 in our device geometry. The experimental results for $X_D$ yield a value of 16: this discrepancy between theory and experiment is probably due to small, yet non-negligible, absorption of SPPs by charged excitons as they propagate through the WSe$_2$, which increases the apparent coupling ratio of $X_D$ after normalization. Indeed, Supplementary Fig. 5 shows that there can be sizeable absorption of SPPs due to charged excitons when SPPs propagate through several micrometres of the WSe$_2$ channel. When SPPs propagate through a minimal distance (less than 1 $\mu$m) within WSe$_2$ (Supplementary Fig. 6), the normalized coupling ratio determined by experiment is close to 7, in good agreement with the theoretical calculations. Figure 3b shows that the value of the normalized coupling ratio in WSe$_2$ is large not only for the neutral exciton peak $X_0$ at 731 nm, but also for the L1 peak at 740 nm.
the normalized coupling ratio of L1 is \( \sim 3 \), but increases significantly and reaches a value of \( \sim 16 \) just when the Fermi level reaches the VB maximum \((V_g \approx -2.5 \text{ V})\) and the CB minimum \((V_g \approx 0 \text{ V})\). A plot of normalized coupling ratios for MoSe\(_2\) does not show a comparable feature (Supplementary Fig. 7).

The origin of optical transitions with an out-of-plane dipole moment (XD and L1) in WSe\(_2\) can be understood by examining the band structure of monolayer TMDs. At the CB minimum and VB maximum of monolayer TMDs, that is, the K and K’ points in reciprocal space, the electronic wavefunctions can be characterized by their transformation properties under a 120° rotation (R) about the surface normal (z axis) and a reflection (P) in the TMD plane (x–y plane, Fig. 4a). Each orbital wavefunction carries a magnetic quantum number \( m \) (only \( m \) modulo 3 matters because of the reduced rotational symmetry) and a parity \( p \) (odd: \( p = -1 \); even: \( p = 1 \)). Selection rules dictate that light circularly polarized in the x–y plane \( (\sigma_i) \) can only induce transitions between states with the same parity and with magnetic quantum numbers differing by one. By contrast, light polarized linearly along the z axis couples states with opposite parity and identical magnetic quantum numbers.

Monolayer TMDs exhibit strong spin–orbit coupling proportional to \( L \cdot S \), where \( L \) and \( S \) are the orbital and spin angular momentum, respectively. The spin–orbit interaction leads to a large spin splitting in the VBs (on the order of several hundred meV\(^{18,19}\)) and a much smaller splitting in the CBs. The latter is because the spin degeneracy in the CB is only lifted to second order\(^5,6,8\) by the SOC term \( L + S \), which mixes different orbital and spin wave functions. Notably, the splitting is of opposite sign for WSe\(_2\) and MoSe\(_2\) (refs 5, 6, 8) (the band orderings for WSe\(_2\) and MoSe\(_2\) are shown in Fig. 4b,c). Owing to the SOC mixing term, spin is no longer an exact quantum number and nominally spin-forbidden transitions, associated with dark exciton states, are in principle possible, albeit weakly. We note that the spin directions in Fig. 4b,c only denote the dominant spin direction. Two of the four possible transitions at the K point are between bands with the same dominant spin directions and are therefore optically

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**Figure 2 | Gate-dependent far-field and SPP-coupled photoluminescence spectra in WSe\(_2\) and MoSe\(_2\).** a–d. Gate-voltage \((V_g)\)-dependent FF-PL (a) and SPP-PL (b) spectra of WSe\(_2\), and FF-PL (c) and SPP-PL (d) spectra of MoSe\(_2\). The intensity is plotted on a linear scale from low (dark blue) to high (yellow). The photoluminescence intensity of a is normalized with respect to that of b (c is normalized with respect to d) so that the intensity of the charged exciton \( X_T \) at zero gate voltage is equal. Dashed lines correspond to boundaries where the neutral exciton \( X_0 \) exists in FF-PL, and correspond to the chemical potential being inside the bandgap region (i). In b, a new feature \( X_D \) emerges in the same \( V_g \) range as the neutral exciton. Negative (positive) gate voltages correspond to p (n) doping. The BN gate dielectric thickness is 8 nm for the WSe\(_2\) sample and 10 nm for the MoSe\(_2\) sample.
exciton state.

Figure 4 | Band structure and optical transitions in WSe₂ and MoSe₂ in the presence of spin-orbit coupling. a, Crystal structure of TMDs (MX₂) and two of its symmetries (three-fold rotation axis R and reflection plane P). b, c, Allowed transitions at the K point for WSe₂ (b) and MoSe₂ (c). For the K valley, the allowed transition (black solid arrow) is circularly polarized (σ⁺). Coloured arrows indicate the dominant direction of the electronic spin. Due to spin–orbit coupling, spin is not an exact quantum number. In WSe₂ (b), the spin-flip transition between the upper VB and the lower CB is weakly allowed and has a transition dipole polarized in the out-of-plane (z) direction. The transition between the lower VB and the upper CB is strictly dipole forbidden. In MoSe₂ (c), the spin splitting of the CB is opposite, leading to different band ordering.

Figure 3 | Gate-dependent enhancement of the neutral and charged dark exciton state. a, FF-PL (blue) and SPP-PL (red) spectra of WSe₂ normalized to the intensity of the charged exciton X₁ at different gate voltages. X₀ and X₀ represent neutral bright and dark excitons. The L₁ peak also brightens up in SPP-PL. b, Normalized coupling ratio, defined as the SPP-PL intensity divided by the FF-PL intensity, both normalized by the bright charged exciton intensity, as a function of gate voltage.

The emergence of L₁, a z-polarized transition outside the bandgap region, may indicate the formation of dark charged excitons. Once the Fermi level reaches the band edge of either the CB or VB, features corresponding to the bright and dark neutral excitons disappear, suggesting that these neutral excitons bind with free carriers to form charged excitons (trions or polarons). The peak L₁ may thus originate from charged dark excitons that form when neutral dark excitons bind with free electrons and holes. It should be noted that similar suggestions have been made using the observation of L₁ brightening under an in-plane magnetic field. The band structure of WSe₂ dictates that a dark charged exciton should form through the binding of a dark neutral exciton ‘bright’. For the remaining two transitions that are nominally ‘dark’, the transition dipole moment should be along the z direction because SOC only couples states with opposite parity. Including magnetic quantum numbers, group theoretic considerations dictate that only the transition connecting to the upper VB is allowed with z-polarized light. The strength of the out-of-plane dipole moment is predicted to be weak, approximately a hundred times smaller than the in-plane bright exciton dipole moment. However, because the energy scale associated with the sample temperature (∼0.4 meV at 4 K) is much smaller than the bright/dark exciton energy splitting of ∼40 meV, the exciton population at thermal equilibrium is almost entirely in the dark exciton state and the dark exciton emission should be visible as long as the z-polarized light can be collected, as in the case of SPP-PL.

These band structure and SOC considerations strongly suggest that the X₀ feature we observe in SPP-PL of WSe₂ (Figs 2b and 3), with its z-polarized dipole orientation, corresponds to the dark exciton described in Fig. 4b. In contrast, in MoSe₂ SPP-PL (Fig. 2d), the corresponding feature is absent (Supplementary Figs 2 and 7), because the dark exciton has a higher energy than the bright exciton and thus should not be observed in our experiment. We note that the X₀ feature in WSe₂ lies 42 meV below the bright exciton transition (X₀), similar to recently observed dark excitons under the application of a large (up to 30 T) in-plane magnetic field. The small difference in bright/dark exciton energy splitting (42 meV in our case versus 47 meV in magnetic-field studies) probably originates from different experimental conditions that can modify the dielectric environment and the band structure of WSe₂ (refs 24, 25). hBN encapsulated WSe₂ on top of silver in our measurements versus unpassivated WSe₂ on SiO₂ (refs 22, 23).

The temperature dependence of the exciton energy splitting (42 meV in our case versus 47 meV in experimental conditions that can modify the dielectric environment and the band structure of WSe₂ (refs 24, 25). hBN encapsulated WSe₂ on top of silver in our measurements versus unpassivated WSe₂ on SiO₂ (refs 22, 23).
with an electron/hole in the other valley. Bright charged excitons are formed, on the other hand, by the binding of a bright neutral exciton with an electron/hole from the same or opposite valley\textsuperscript{29}. Figure 3b also shows significant brightening of the L1 feature as the Fermi level reaches the VB maximum \( (V_F \approx -2.5\) V) and the CB minimum \( (V_F \approx 0\) V): this observation may suggest the reorientation of a transition dipole moment at those points or alternatively a change in the relative population of states with in-plane versus out-of-plane transition dipole moments. The exact reasons for the observation is not understood at the moment, and requires further experimental and theoretical analyses.

We have demonstrated a new method for SPP-assisted near-field spectroscopy that enables measurement of the dipole orientation of two-dimensional excitons. The technique does not require a high magnetic field and can be easily integrated with other devices, making it easily accessible, versatile and technologically relevant. We use this method to observe nominally spin-forbidden dark excitonic states in monolayer WS\textsubscript{2}, with out-of-plane dipole orientation, thus directly probing the SOC physics in TMD monolayers.

Our method opens up avenues for controlling the fundamental properties of atomically thin materials and the realization of new potential applications. It should enable detailed studies of indirect dark excitons\textsuperscript{30} and the interaction between out-of-plane excitons and phonons in van der Waals heterostructures\textsuperscript{31}. Due to the negligible coupling to free-space electromagnetic modes, the near-field coupling to tightly confined nanophotonic and plasmonic modes should play the dominant role in radiative interactions of dark excitons under a wide variety of experimental conditions. These can be used to realize active metasurfaces based on spatial modulation of exciton lifetimes and to explore schemes for chiral photonics\textsuperscript{30} and quantum optics\textsuperscript{31}. Finally, the dark excitons can have a long lifetime\textsuperscript{32},\textsuperscript{33}, which may be used to study transport and electrostatic manipulation of excitonic matter in two-dimensional systems\textsuperscript{32},\textsuperscript{33}, with potential applications for information processing and on-chip communication.

Methods
Methods and any associated references are available in the online version of the paper.

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Author contributions

Additional information
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Competing financial interests
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Methods

Single-crystal silver films (250 nm thick) were grown via sputtering on the (0001) face of 4H-SiC substrates at 350 °C with a buffer layer of Ti (90 nm thick), grown at 500 °C. Typical silver films show a root-mean-square roughness of less than 1 nm and exhibit a long propagation length for SPPs\(^5\). Trenches that served as in- and out-coupling structures for SPPs were made using electron-beam lithography and argon ion etching. Thin layers of hBN and monolayers of WSe\(_2\) and MoSe\(_2\) were mechanically exfoliated from bulk crystals onto Si wafers coated with 285-nm-thick SiO\(_2\). Monolayer TMDs were then identified under an optical microscope and verified via photoluminescence measurements. The thicknesses of hBN layers were measured by atomic force microscopy. The hBN/TMD/hBN heterostructures were then assembled and transferred by a dry transfer method\(^3\) onto the patterned single-crystal silver substrates. Afterwards, thin layers of SiN (160 nm; via plasma-enhanced chemical vapour deposition at room temperature) and alumina (30 nm; via atomic layer deposition at 90 °C) were deposited, with the pattern defined by electron-beam lithography. These served as an insulating barrier between the silver substrate and the electrical contacts to the TMDs. Finally, electrical contacts were deposited by electron-beam evaporation of Cr (10 nm)/Au (90 nm) followed by sputtering of another 40 nm of Au, with the dimensions defined by electron-beam lithography. Optical measurements were carried out in a home-built confocal microscope using an objective with a numerical aperture of 0.75 in a 4 K cryostat (Montana Instruments). Two galvo mirrors were used to scan the excitation and collection spots independently on the sample.

Data availability. The data that support the plots within this paper and other findings of this study are available from the corresponding author upon reasonable request.